

REMARKS

This application is a continuation of parent Application No. 08/483,731.

Applicant has cancelled claims 1-76 without prejudice and has added new claims 77-147 for prosecution in this continuation application. No new matter has been added by any of the amendments.

In Application No. 10/385,386, which is also a continuation of parent Application No. 08/483,731, Examiner Craig E. Church required an election of species with the result that claims 143-162 and 176-187, drawn to patterned particle beam lithography, classified in class 216, subclass 2 (Group XVI), were withdrawn from consideration. Accordingly, applicant has filed this continuation application directed to the subject matter of claims 143-162 and 176-187 (applicant has renumbered claims 143-162 and 176-187 as claims 77-108).

The specification has been amended to update cross references to other patent documents and to correct minor typographical errors. No new matter has been added by the amendment of the specification.

An early and favorable action is respectfully
requested.

Respectfully submitted,



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